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Reflectionless Tilted Grating Couplers With Improved Coupling Efficiency Based on a Silicon Overlay — Source link

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Tilted silicon-on-insulator grating coupler with improved fiber coupling efficiency and low back reflection based on a silicon overlay

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Abstract—With the help of a silicon overlay, the enhancement in the coupling efficiency of a tilted grating coupler for siliconon-insulator waveguides is demonstrated by means of simulation and experiment. The fabricated tilted focusing grating couplers show a coupling efficiency of -2.2 dB in combination with a back-reflection of around -40 dB when excited from the silicon waveguide.

Index Terms—Tilted grating coupler, back-reflection, coupling efficiency

I. INTRODUCTION

Grating couplers (GCs) are used in photonic integrated circuits (PICs) to couple light between optical waveguides and free space optical components or fibers [1]. They provide a simple method for wafer scale testing of PICs, which can help to reduce the cost of production. For a specific GC design, both its back-reflection and its coupling efficiency (to free space or to a single-mode fiber) should be optimized over the required spectral band. On one hand it is important to reduce the backreflection for light incident on the GC from the waveguide. The back-reflection of a commonly used one-dimensional (1D) GC comes from two major sources: the second order reflection of the GC and the Fresnel reflection on the boundary between the input waveguide and the GC. The second order reflection is usually suppressed by setting the zenith of the output light ϕ_0 (the angle of the output light with respect to the chip normal) to a non-zero value (e.g. 10°) [2]. By improving the mode matching conditions, the Fresnel back-reflection can also be reduced [4], [5]. Alternatively the back-reflection can be strongly reduced by directing the reflection away from the input waveguide by means of a tilted grating coupler [3]. On the other hand, studies on improving the coupling efficiency and bandwidth of a GC have also been intensively reported [2], [6]. We reported that a silicon overlay can be deposited on top of a 1D GC to increase the coupling efficiency [7], [8]. However, there has been little work so far on the designs that combine high coupling efficiency with low back reflection in a CMOS-compatible SOI platform. In this letter, we report

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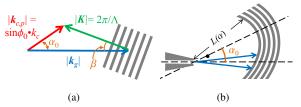


Figure 1. (a) Wave vector relations in a tilted 1D grating coupler; (b) a tilted focusing grating coupler.

about the coupling efficiency of different tilted 1D GC and tilted focusing grating coupler (FGC) designs with Si overlays, by means of simulation and measurement. Unlike many other designs that are fabricated with the use of electron beam lithography, our designs are realized in an advanced CMOScompatible platform and thus are suitable for high volume production.

II. THEORY ON TILTED GRATING COUPLERS WITH SI OVERLAY

Two different tilted GC designs, the tilted 1D GC and the tilted FGC, can be used to suppress back reflections for light sent from the input waveguides to the GCs, because these reflections are not sent back directly to the input waveguides. For a tilted 1D GC, the relations among the wave vector of the input light $(\vec{k_g})$, the reciprocal lattice vector of the grating (\vec{K}) , and the projection of the output light wave vector onto the chip surface $(\vec{k_{c,p}})$ are shown figure 1(a). According to these relations, the tilt angle of the GC β and the grating period Λ are calculated according to the required direction of the output light, being described by the zenith ϕ_0 and the azimuth α_0 , with the following equations:

$$\beta(\phi_0, \alpha_0) = \arctan\left(\frac{n_{c,p}\sin\alpha_0}{n_g^0 - n_{c,p}\cos\alpha_0}\right), \quad (1)$$

$$\Lambda(\phi_0, \alpha_0) = \frac{\lambda_0 \cos \beta(\phi_0, \alpha_0)}{n_q^0 - n_{c,p} \cos \alpha_0},$$
(2)

where $n_{c,p} = n_c \sin \phi_0$, λ_0 is the vacuum wavelength of the light, n_g^0 is the effective index of the light propagating in the waveguide corrugated by the grating, and n_c is the refractive index of the superstrate (air in this case), respectively. Note that the refraction of light on the boundary of the GC and the slab region is not considered here, because the angle change due to refraction is relatively small (< 1°) in our designs.

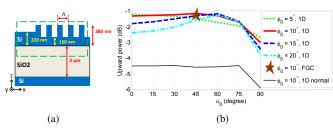


Figure 2. (a) The cross-section of a grating coupler with a silicon overlay; (b) Fractions of light coupled into the upward direction of different tilted GCs as a function of the azimuth α_0 . The curves called "1D" are for the tilted 1D GCs with a 160 nm thick Si overlay, the curves called "1D normal" are for the tilted 1D GCs without Si overlay, and the curve called "FGC" is for a tilted FGC designed for $\alpha_0 = 45^{\circ}$.

To use the tilted 1D GC for coupling light between a wire waveguide (with a width of 450 nm) and a single-mode fiber in free space, a long taper is normally needed between the waveguide and the GC. An FGC design can be used to dramatically reduce the length of this taper [9]. The curves of an FGC are described in a polar coordinate system as [3]

$$r(q,\alpha) = \frac{(q-q_0)\lambda_0}{n_q^0 - n_c \sin \phi_0 \cos(\alpha - \alpha_0)} + L(\alpha), \quad (3)$$

where q_0 and $q \in N$ are the indices of the first and each line in the grating, respectively, and $L(\alpha)$ is the distance between the first line and the input waveguide (see fig. 1(b)). $L(\alpha)$ determines the waist size of the output light beam and has been discussed in detail in [3]. In the tilted FGCs, the azimuth α_0 is set different from 0° or 180° , in order to avoid the reflection from going back to the input waveguide.

According to [7], [8], an extra Si overlay (polycrystalline or amorphous) with a thickness of 160 nm can be locally deposited on top of a 1D GC to increase the fraction of the upward diffracted power, so as to increase the waveguide-tofiber coupling efficiency. The cross section of such a GC is shown in figure 2(a). In this paper, the 3D finite difference time domain (FDTD) method is used to analyze the power directionality of a tilted GC with a Si overlay. Considering the speed of the 3D FDTD simulations, the simulation domains (the dashed box in figure 2(a)) do not include the lower boundary of the 2 μ m oxide layer. This is not a bad approximation according to [7], which demonstrated that the influence of this boundary is less important for the GCs with Si overlays. The widths of the input waveguide and the GC are set as 4 μ m to further reduce the simulation time. For calculating the fraction of the upward diffracted power, this is a good approximation for the real case (10 μ m width). However, this simplification can not be applied to tilted FGCs, which have more complex layouts. As a result, the simulations of tilted FGCs are more time and memory consuming compared to those of tilted 1D GCs.

The fractions of the upward coupled power of four groups of tilted 1D GC designs ($\phi_0 = 5^\circ, 10^\circ, 15^\circ$ and 20°) with 160 nm Si overlays are simulated for different α_0 values, and the results are illustrated in figure 2(b). In the simulations, n_g^0 is set to 2.75 to calculate the grating period and tilt angle according to eq. 1 and eq. 2, and $n_c = 1.0$, and the duty cycle

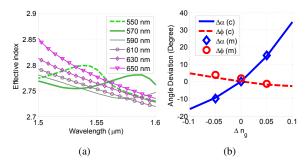


Figure 3. (a) The effective indices of 1D grating couplers with silicon overlay as a function of wavelength and grating period. In this case $\beta = 0^{\circ}$. (b) the deviation of α_0 and ϕ_0 as a function of Δn_g . The solid and curved lines are calculated values. The \Diamond and \bigcirc symbols are the measured values.

of the gratings is set to 50% everywhere. It can be seen that the upward power of the tilted GC designs with $\phi_0 = 10^\circ$ is always larger than -1.5 dB for $\alpha_0 \leq 60^\circ$, and its variation is also smaller than that of the other titled GCs. So the designs with $\phi_0 = 10^\circ$ are chosen for further discussions in this letter. When $\alpha_0 \geq 75^\circ$, the upward coupled power drops rapidly. This is because the period Λ is approaching the value that supports strong 2nd order reflections as α_0 is increasing. For comparison, the upward power coupling efficiency of a tilted FGC designed for $\alpha_0 = 45^\circ$ with the same Si overlay is also simulated and shown in figure 2(b). It is seen that the upward power of the tilted FGC with Si overlay has a similar value to that of the tilted 1D GC with Si overlay designed with the same α_0 and ϕ_0 . This comparison is used to prove that the upward power of tilted FGCs with Si overlay can be simply estimated by using the results of tilted FGCs with Si overlay, which can be simulated more easily. A group of tilted 1D GCs without the Si overlay (with 70 nm trench depth in the grating) are also simulated and shown in figure 2(b). Since the lower boundary of the oxide box is not considered in this simulation, the real upward powers for the normal tilted GCs can be 1 dB to 1.5 dB greater than these calculated values. But they are still less than those of the tilted GCs with Si overlays.

One problem with this design is that n_a^0 can be wrongly estimated. The effective indices of 1D GCs with $\beta = 0^{\circ}$ as functions of Λ and λ are calculated by means of 2D FDTD simulation. In the simulation, the phase slope $\Delta \Phi / \Delta L$ of the light in the grating region in its propagation direction is calculated first, and then the effective index is obtained according to the formula $n_q^0 = \Delta \Phi / \Delta L \cdot \lambda_0 / 2\pi$. The results are shown in figure 3(a). It can be seen that these relations are quite complex, especially when Λ is small enough to introduce strong 2nd order reflections (see the curves for $\Lambda = 590$ nm and $\Lambda = 610$ nm in figure 3(a)). Even if an accurate effective index value is obtained from simulation, the variation in this value caused by fabrication uncertainty is hardly controllable. As a result, the value of n_g^0 used in the design equations mentioned above is usually different from the real effective index of the grating. For clarification, a symbol n_g is used to stand for the index value used in the design, in order to be distinguished from the real index of the grating n_a^0 . The difference between n_g and n_q^0 causes a direction change in the output light with the required wavelength and thus a central wavelength shift in the transmission spectrum. To find out the value of n_g^0 in real devices, one can make a scan of n_g and test the corresponding transmissions in measurement. However, scanning n_g is not a proper solution in many cases. Since the central wavelength shift is caused by the direction change of the output light with the required wavelength, there is a way to shift the central wavelength back to the required value by adjusting the direction of the output light. The new directions (α'_0 and ϕ'_0) can be theoretically calculated according to the following equations:

$$\alpha'_{0} = \alpha_{0} + \arctan\left(\frac{\Delta n_{g}\sin\alpha_{0}}{n_{c,p} - \Delta n_{g}\cos\alpha_{0}}\right), \quad (4)$$

$$\phi_0' = \arcsin\left(\frac{\sqrt{n_{c,p}^2 + \Delta n_g^2 - 2n_{c,p}\Delta n_g \cos\alpha_0}}{n_c}\right), \quad (5)$$

where $\Delta n_g = n_g - n_g^0$. For $\alpha_0 = 45^\circ$ and $\phi_0 = 10^\circ$, the angle deviations $\Delta \alpha_0 = \alpha'_0 - \alpha_0$ and $\Delta \phi_0 = \phi'_0 - \phi_0$ are shown in figure 3(b). For both the tilted 1D GC and tilted FGC designs, these angle deviations can be used to adjust the output fiber direction.

The simulations of the reflection suppressions in tilted FGCs have already been reported in [10], and for tilted FGCs with Si overlay we have similar results. So they are not elaborated in this letter.

III. MEASUREMENT RESULTS AND DISCUSSIONS

A number of tilted focusing grating couplers with amorphous-Si overlays, designed for $\alpha_0 = 0^\circ$ or 45° , and $\phi_0 = 10^\circ$, were fabricated through ePIXfab [11]. Since different values of n_g were used in the place of n_g^0 in the eq. 3 for different designs, these designs have different grating periods and shapes. For the tilted FGCs designed for $\alpha_0 = 45^\circ$, the transmission spectra and the central wavelengths are changed corresponding to the different n_q values in the design (see figure 4(a) and figure 4(b)). It can be seen that, for the tilted GCs with silicon overlay, the waveguide-to-single mode fiber coupling losses are reduced by more than 2 dB compared to a standard grating coupler ("ref" in figure 4(a), without Si overlay, 70 nm etch depth, 625 nm period), and it is also 2 dB lower than the tilted FGCs without Si overlay $(\alpha_0 = 45^\circ, 70 \text{ nm etch depth})$ [3]. The lowest transmission loss is around -2.2 dB. The central wavelength decreases linearly as n_a is increasing, with a slope of -0.4 μ m per unit of index. The scanning results show that the real effective index n_a^0 at 1550 nm is about 2.65. As is mentioned above, the central wavelength shift for different n_q can be compensated by changing the fiber direction, which was observed in the measurements. The measured deviations of the output light $(\Delta \alpha_0 \text{ and } \Delta \phi_0)$ are shown in figure 3(b). It is seen that the measured results agree well with the theoretically calculated ones.

The back reflections of tilted FGCs with $\alpha_0 = 0^\circ$ and 45° are obtained by measuring the transmission fringes using an optical frequency domain reflectometry (OFDR) method. In order to split the reflections from the fiber end and those from

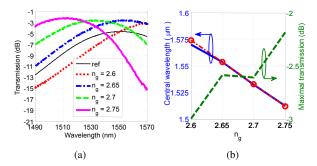


Figure 4. (a) Measured transmission spectra of four tilted FGCs with Si overlays with different n_g values, $\alpha_0 = 45^\circ$. The "ref" curve stands for the transmission spectrum of a standard GC without any Si overlay. (b) The central wavelengths of the transmission spectra (solid line), and their corresponding coupling efficiency (dashed lines). \bigcirc symbols stand for the fitted values for central wavelengths.

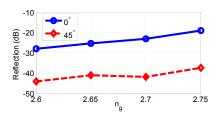


Figure 5. The reflection values for FGCs with $\alpha_0 = 0^\circ$ (solid line) and tiled FGCs with $\alpha_0 = 45^\circ$ (dashed line). Both are with 160 nm thick Si overlay.

the GCs, the end facets of both the input and output fibers are placed far away from the GCs. The results are shown in figure 5. It is found that, for $\alpha_0 = 0^\circ$, the reflections are still considerably large (near -20 dB). For tilted FGCs with $\alpha_0 = 45^\circ$, the reflection averaged in the frequency range from 1490 nm to 1570 nm can be reduced to lower than -40 dB.

IV. CONCLUSIONS

We reported the enhanced transmission in tilted onedimensional grating couplers and tilted focusing grating couplers with the help of a locally deposited silicon overlay. Grating couplers with an enhanced waveguide-to-single mode fiber coupling efficiency (-2.2 dB) and a reduced back-reflection (around -40 dB) are realized with an advanced CMOS compatible technology. Deviations in coupling wavelengths between design and experiment can be compensated by adjusting the directions of the output fiber.

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